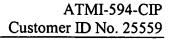


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FORM	Filing Date		October 31, 2003						
(to be used for all correspondence after initial filing)		First Named Inventor		Ziyun Wang					
] :	2826					
		Examiner Name		ГВА					
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Response to Missing Parts/ Incomplete Application Response to Missing Parts under 37 CFR 1.52 or 1.53	Remarks								
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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Ziyun Wang, et al.

Group Art Unit: 2826

U.S. Application No.: 10/699,079

Examiner: TBA

Filed: October 31, 2003

Title: COMPOSITION AND METHOD FOR LOW TEMPERATURE DEPOSITION OF

SILICON-CONTAINING FILMS

CERTIFICATE OF MAILING

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SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Pursuant to 37 C.F.R. §1.56, the attention of the Patent and Trademark Office is hereby directed to the reference(s) listed on the attached PTO-1449. It is respectfully requested that the information be expressly considered during the prosecution of this application, and that the reference(s) be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

□ 1. This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required in accordance with 37 CFR § 1.56 and § 1.97(b).

⊠ 2.		nformation Disclosure Statement is being filed more than three months after the ling date, but before the mailing date of the first Office Action on the merits.
	⊠ a.	I hereby certify that each item of information contained in this Information Disclosure Statement was the first citation of such item by a foreign patent office in a counterpart foreign application, which occurred no more than three months prior to filing the Information Disclosure Statement. 37 C.F.R. §1.97(e)(1).
	□ b.	I hereby certify that no item of information in this Information Disclosure Statement was cited in a communication from a foreign patent office in a counterpart foreign application or, to my knowledge after making reasonable inquiry, was known to any individual designated in 37 CFR §1.56(c) more than three months prior to the filing of this Information Disclosure Statement. 37 C.F.R. §1.97(e)(2).
	□ c.	Attached is our check no in the amount of \$180 in payment of the fee under 37 C.F.R. §1.17(p). Please credit or debit Deposit Account No. 50-0860 as needed to ensure consideration of the disclosed information. Two duplicate copies of this paper are attached.
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1 4.	(other)) :

Applicant does not believe that any additional fee is due in connection with the foregoing. However, any deficiencies may be charged to the deposit account 50-0860.

Respectfully submitted,

William F. Ryann

Registration No. 44,313 Attorney for Applicant

Advanced Technology Materials, Inc.

7 Commerce Drive Danbury, CT 06810

Agent Ref: ATMI-594-CIP

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		Precursors for Plasma-Enhanced Chemical Vapour Deposition (PE-CVD) of Silicon Nitride, Z, anorg. Allg. Chem. 1993, Vol. 619, pages 1347-1352.						
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